

TJK/180/L.W.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of Hong-Sik BYUN et al.) PLASMA PROCESSING APPARATUS
Korean Appln. No. 2000-30050)
Korean Filing Date: June 1, 2000)

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

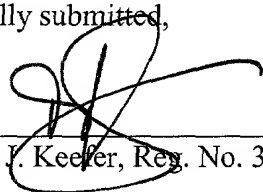
Please amend the subject application as follows:

--CROSS REFERENCE TO RELATED APPLICATION

This application claims the priority of Korean patent application Serial No. 2000-30050
filed on June 1, 2000.-

Respectfully submitted,

Date: 5/31/01
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